

Delta-doped imagers for UV and EUV applications

S. Nikzad, T.J. Jones, T.J. Cunningham, P.W. Deelman, and S.T. Elliott
Center for Space Microelectronics Technology
Jet Propulsion Laboratory, California Institute of Technology, Pasadena, CA 91109

Abstract

The large imaging format, high sensitivity, compact size, and ease of operation of silicon-based sensors have led instrument designers to choose them for most visible-light imagers and spectrometers for space-based applications, and this will probably remain the case in the near future. In fact, technologies presently under development will tend to strengthen the position of silicon-based sensors. CCD-CMOS hybrids currently being developed may combine the advantages of both imagers and new high-gain amplifiers and could permit photon-counting sensitivity even in large-format imagers. Back-illumination potentially enables silicon detectors to be used for photometry and imaging applications for which front-illuminated devices are poorly suited. Generally, back illumination requires treatment of the back surface such as delta doping.

Delta-doped CCDs were developed at the Microdevices Laboratory at the Jet Propulsion Laboratory in 1992. Using molecular beam epitaxy, fully-processed thinned CCDs are modified for UV enhancement by growing 2.5 nm of Boron-doped silicon on the back surface. Named delta-doped CCDs because of the sharply-spiked dopant profile in the thin epitaxial layer, these devices exhibit stable and uniform 100% internal quantum efficiency without hysteresis in the visible and ultraviolet regions of the spectrum. In this paper we will discuss, performance of delta-doped CCDs in UV and EUV, our in-house thinning capability, bonding approaches for producing flat focal plane arrays, and in-house capabilities of directly applied antireflection coatings. Recent activities on the extension of delta doping technology to other imaging technologies will also be presented.

Introduction

The large format, high resolution, low noise, and maturity of technology renders CCDs as detector of choice for many scientific applications. Standard frontside-illuminated CCDs do not respond in the UV because of short absorption of photons in this wavelength range. Untreated back-illuminated silicon CCDs have limited sensitivity to radiation with short penetration depth (e.g., UV photons and low-energy particles), due to the surface depletion caused by the inherent positive charge in the native oxide. Because of surface depletion, internally-generated electrons are trapped near the irradiated surface and therefore cannot be transported to the detection circuitry. This surface potential can be eliminated by low-temperature molecular beam epitaxial (MBE) growth of a delta-doped layer on the Si surface. This effect has been demonstrated through achievement of 100% internal quantum efficiency for UV photons detected with delta-doped CCDs.

Figure 1 schematically shows the structure of a delta doped CCD. A 2.5 nm delta-doped Si layer is grown on the back surface of thinned, fully-processed CCDs at low-temperature. Processing of delta-doped CCDs has been described previously.^{1,2} Delta-doped CCDs have been extensively tested and have shown 100% internal quantum efficiency in the ultraviolet and visible part of the spectrum indicating that the deleterious backside potential well responsible for the detector dead layer has been effectively eliminated. Because the delta-doped layer is incorporated directly into the silicon lattice, the modified CCDs are robust enough to withstand direct deposition of anti-reflection coatings for enhanced UV quantum efficiency.

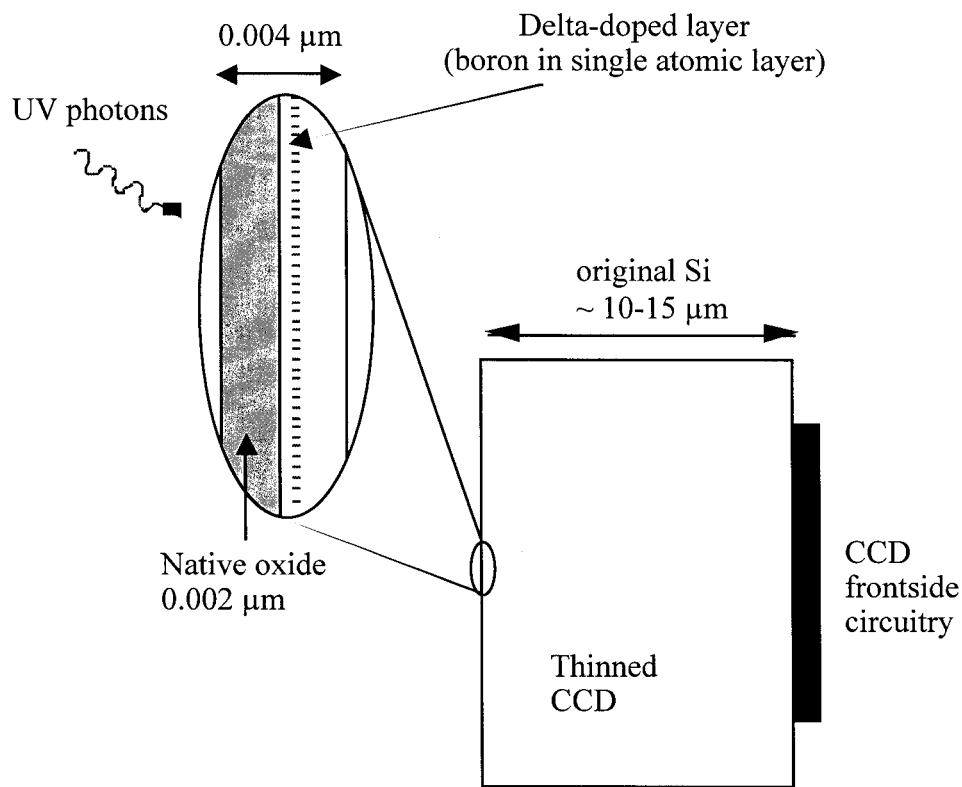


Figure 1. Cross section schematic of a delta-doped CCD. The epitaxially-grown delta-doped layer on the back surface of a thinned CCD places a high density of boron atoms approximately 0.5 nm below the silicon epilayer surface and protected by an oxide overlayer.

UV and EUV Characterization of Delta-doped CCDs

The quantum efficiency (QE) and stability of delta-doped CCDs in the UV and visible regions of the spectrum has been extensively measured. Figure 1 shows the typical quantum efficiency in the 250-700 nm region of the spectrum and the enhancement of the QE in the 300-400 nm region by direct deposition of single layer HfO_2 .² The solid line in figure 1 is the silicon transmittance which represents 100% internal quantum or the maximum QE that can be obtained without addition of antireflection coatings. We have also measured the QE of delta-doped CCDs in the 121.6-310 nm region of the spectrum. It was shown in those measurements that the delta-doped CCD shows 100% internal QE throughout the entire 120-700 nm waveband.

Applications in astronomy require stable device performance. Figure 2 shows quantum efficiency data over a three-year period. No degradation of the device quantum efficiency was observed. The device stability with respect to history of illumination has also been examined. Increasing the exposure time by a factor of 100 and returning to the original exposure time yielded identical quantum efficiency for the delta-doped CCD, demonstrating that no quantum efficiency hysteresis exists in the device.

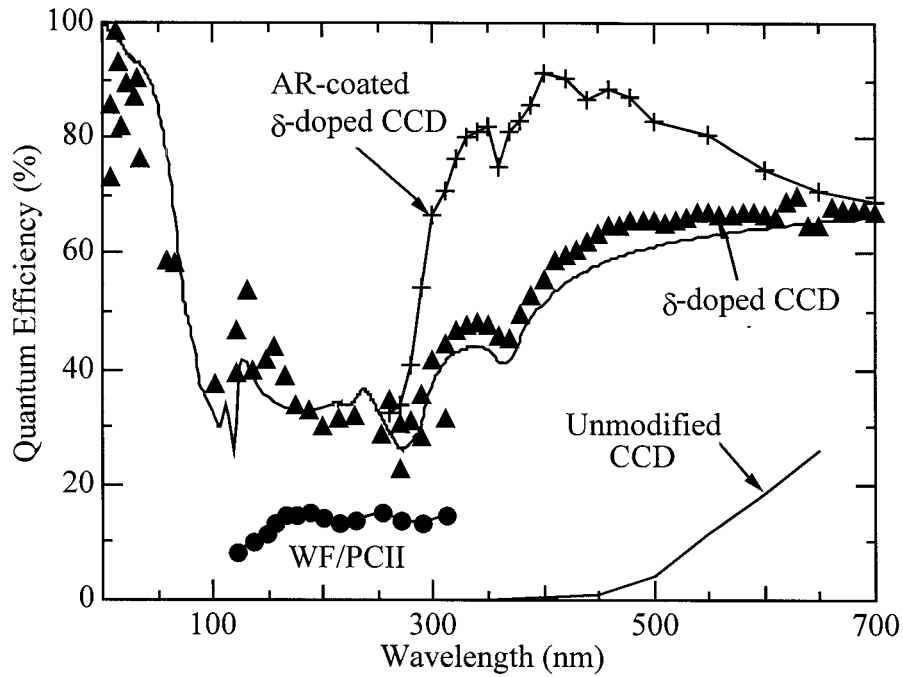


Figure 2. Quantum efficiency of a bare delta-doped CCD (triangles) compared with solid line (Si transmittance) shows 100% internal QE. QE is enhanced by the addition of anti-reflection coatings optimized for the 300-400 nm regions .

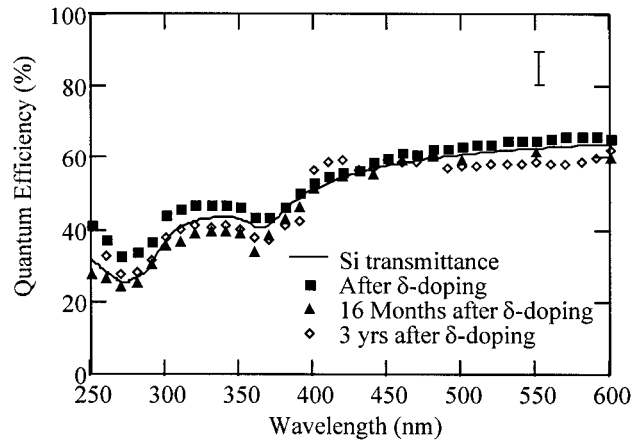


Figure 3. QE measured over a three-year period on the same delta-doped 512-by-512-pixel Reticon CCD. The CCD was stored unprotected in a laboratory environment. The error bars represent the accuracy ($\pm 5\%$) of the measurement systems used.

Low-energy particle detection with delta-doped CCDs

Similar to UV photons, low-energy particles deposit a significant fraction of their energy within a few nanometers of the surface, therefore, frontside-illuminated or untreated back-illuminated CCDs cannot detect low-energy particles. Quantum efficiency measurements in the UV indicate that electrons generated near the surface of delta-doped CCDs are detected efficiently and delta-doped CCDs are promising as imaging detectors of low-energy particles. We have measured the response of delta-doped CCDs to electrons in the 50-1500 eV energy range using both an

indirectly-heated cathode electron source in a custom UHV chamber and a scanning electron microscope.^{3,4} All devices were fully-characterized using UV illumination prior to the electron measurements.

Figure 4 shows the electron quantum efficiency of a delta-doped CCD plotted as a function of incident energy. Quantum efficiency was calculated by dividing the measured current from the CCD configured in photodiode mode to the measured electron beam current (measured by a Faraday cup), which is equivalent to the number of electron-hole pairs detected divided by the number of incident electrons. The measured quantum efficiency of the delta-doped CCD increases with increasing energy of the incident beam. The dependence of quantum efficiency on incident energy is due to the complicated interaction of electrons with silicon which results in the generation of multiple electron-hole pairs in the cascade initiated by each incident electron. A significant fraction of the incident energy is undetected, due to backscattering of incident electrons and other energy dissipation mechanisms (e.g., secondary and Auger electron emission). Multiple electron-hole pair production, also known in the literature as quantum yield, is also observed in the measured UV and x-ray response of delta-doped CCDs and other devices. Quantum yield greater than unity has been previously observed in backside-illuminated CCDs modified using the flashgate⁵ and ion implantation⁶ at electron energies greater than 1 keV.

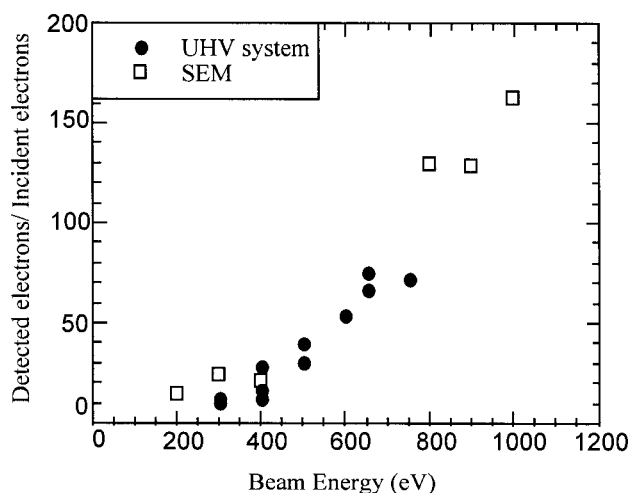


Figure 4 Ratio of detected electrons to incident electrons as a function of energy. The response of the CCD increases with increasing energy as result of multiple electron-hole pair generation.

In measurements conducted in our laboratory, we report the use of CCDs to image electrons. Images of 500 eV electrons with the delta-doped CCD show excellent qualitative similarity to UV images at 250 nm, with similar contrast between delta-doped and control regions of the CCD.

Field observations and feedback from scientific community

Delta-doped CCDs have been used recently in collaborations with several scientists in a number of field observations. In collaboration with Caltech, a delta-doped CCD was used to image galaxies in the near UV at Caltech's Palomar observatory. In a sounding rocket experiment in collaboration with the University of Colorado, a delta-doped CCD was used as the detector in the spectrograph for ozone concentration measurements in the upper atmosphere. Use of delta-doped CCDs in very high precision photometry in collaboration with NASA Ames has been carried out showing that delta-doped CCDs have the dynamic range and stability necessary for high precision photometry.

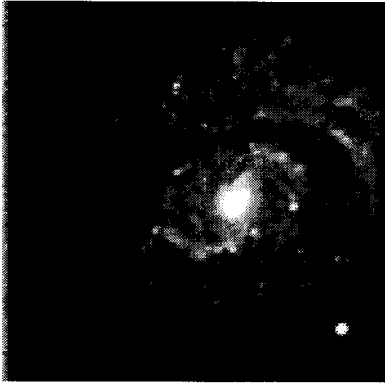


Figure 5 . Image of a spiral galaxy taken at the Palomar observatory. For comparison the same image in the visible is shown in 5b.

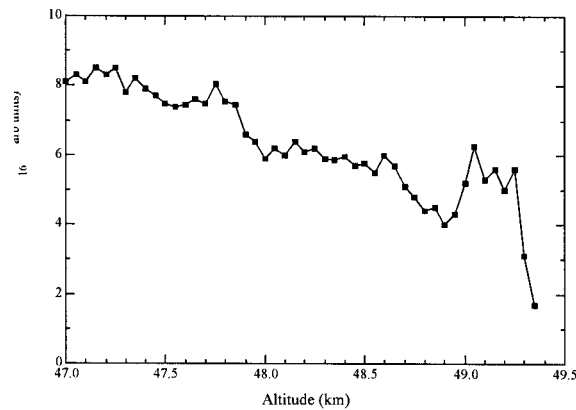


Figure 6 . Picture of HOMER sounding rocket and b) a sample of data that was taken during the rocket flight.

Acknowledgments

The authors gratefully acknowledge the invaluable assistance of Drs. L.D. Bell, M.E. Hoenk, S. Manion, T. Van Zandt, J. Trauger, M. Lesser, J. McCarthy, and Mr. W. Proniewicz. The work presented in this paper was performed by the Center for Space Microelectronics Technology, Jet Propulsion Laboratory, California Institute of Technology, and was jointly sponsored by the National Aeronautics and Space Administration, Office of Space Science and the JPL's Director Research and Development Fund.

References

1. M.E. Hoenk, P.J. Grunthaner, F.J. Grunthaner, M. Fattahi, H.-F. Tseng and R.W. Terhune, Appl. Phys. Lett., 61 (9) 1084 (1992).
2. S. Nikzad, M.E. Hoenk, P.J. Grunthaner, R.W. Terhune, R. Wizenread, M. Fattahi, H.-F. Tseng, and F.J. Grunthaner, Proc. of SPIE, 2217, *Surveillance Technologies III*, April 4-8, Orlando, Fl. (1994).
3. A. Smith, Q. Yu, S.T. Elliott, T.A. Tombrello, and S. Nikzad, Proc. of the MRS, 448, Boston, Dec. 3, (1996).
4. S. Nikzad, A. Smith, T. Elliott, T.A. T.J. Jones, Tombrello, and Q. Yu, Proc. SPIE, 3019, Feb. 11, San Jose, (1997).
5. T. Daud, J.R. Janesick, K. Evans, and T. Elliott, Opt. Eng., 26 (8) 686 (1987).
6. D.G. Stearns and J.K. Wiedwald, Rev. Sci. Instrum. 60 (6)1095 (1989).